

Stereoselective Epoxidation of Acyclic Allylic Ethers Using Ketone-Oxone® System

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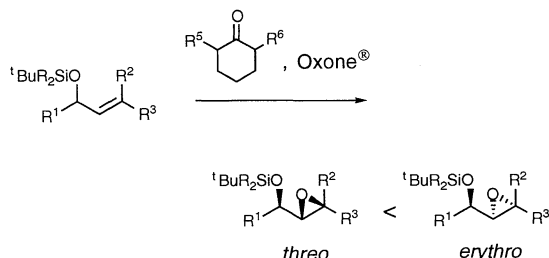
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The stereoselective oxidation of acyclic allylic silyl ethers with dioxiranes generated *in situ* from Oxone® and ketones provided *erythro* epoxides.

Dioxiranes are powerful and versatile reagents as oxidants in organic synthesis.¹ We have shown that dioxiranes generated *in situ* from cyclohexanone derivatives in a homogeneous solvent system play a major role as bulky oxidants and stereoselectively oxidize cyclic olefins yielding *trans* epoxides.²

Stereoselective epoxidation of acyclic allylic alcohols with peracid or metal/alkyl peroxide was reported by several workers³ and they revealed the relation between selectivity and structure in epoxidation process of allylic alcohols. Adam *et al.* investigated the epoxidation of acyclic allylic alcohols with dimethyldioxirane and found *threo* selectivity and the formation of enones.⁴

In this paper, we describe the epoxidation of acyclic allylic silyl ethers, protected allylic alcohols, using the ketone-Oxone® (active constituent KHSO₅) system in order to obtain *erythro* epoxides (Scheme 1).⁵



Scheme 1.

The epoxidation of substrates with dioxiranes generated *in situ* were carried out in a homogeneous solvent system (CH₂Cl₂-MeOH-buffer) under basic condition (pH 11) as reported earlier.²

Different types of five acyclic allylic ethers were epoxidized (Figure 1) and the results are summarized in Table 1.

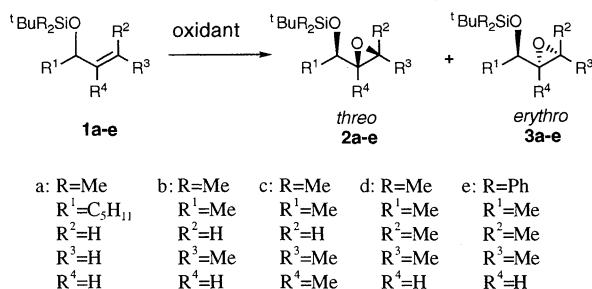
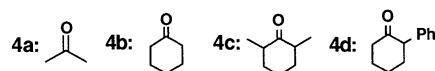


Figure 1.

Table 1. Stereoselective epoxidation of acyclic allylic ethers

entry	olefin	oxidant	method ^a	yield/% ^b	<i>threo</i> : <i>erythro</i> ^c
1	1a	<i>m</i> -CPBA	A	74	51 : 49
2	1a	4c, Oxone	B	21	26 : 74
3	1a	4d, Oxone	B	28	25 : 75
4	1b	<i>m</i> -CPBA	A	90	66 : 34
5	1b	4a, Oxone	B	54	43 : 57
6	1b	4b, Oxone	B	84	42 : 58
7	1b	4c, Oxone	B	50	29 : 71
8	1b	4d, Oxone	B	84	22 : 78
9	1c	<i>m</i> -CPBA	A	91	57 : 43
10	1c	4c, Oxone	B	24	58 : 42
11	1c	4d, Oxone	B	13	61 : 39
12	1d	<i>m</i> -CPBA	A	78	57 : 43
13	1d	4b, Oxone	B	81	32 : 68
14	1d	4c, Oxone	B	54	30 : 70
15	1d	4d, Oxone	B	99	11 : 89
16	1e	4c, Oxone	B	28	10 : 90
17	1e	4d, Oxone	B	94	02 : 98



^aMethod A: A mixture of olefin (1 mmol) and *m*-CPBA (3 mmol) in CH₂Cl₂ was stirred at rt for 3 h. *Method B*: A solution of Oxone (4 mmol) in water was added dropwise to a well-stirred mixture of CH₂Cl₂ (5 ml), MeOH (20 ml) and buffered water (10 ml, pH 11.0, 0.5 M phosphate buffer) containing olefin (1mmol) and ketone (10 mmol) at rt over 6 h. During the addition, the pH of the reaction mixture was kept constant using a pH-stat.^b Isolated yields. ^c Ratios were determined by NMR. In each case, stereochemistry was assigned by correlation with known structures.

Epoxidation with the ketone-Oxone® system gave *erythro* selectivities (entries 2, 3, 5–8, 13–15, 16 and 17) in contrast to low *threo* selectivities with *m*-CPBA (entries 1, 4, 9 and 12). Allylic ether **1c** with an α-substituent showed different selectivities (entries 10 and 11). The use of 2-phenylcyclohexanone **4d** as a ketone in place of 2,6-dimethylcyclohexanone **4c**, resulted in better selectivities and yields of the epoxides. High selectivities and yields were obtained when the trisubstituted olefin was used (entries 15 and 17). In the case of large R¹ or α-substituents present in allylic ethers, yields were low (entries 2, 3, 10 and 11). When a trisubstituted olefin protected by *t*-butyldiphenylsilyl **1e** was treated with 2-phenylcyclohexanone **4d** and Oxone the best selectivity (2 : 98) was given.

Mechanistic approaches of electrophilic additions to acyclic allylic ethers have been reported by several workers.⁶ We propose that the epoxidation with bulky dioxiranes proceeds via the transition states shown in Figure 2. *Erythro* products arise from the transition state I that has the largest group(OSiR₂^tBu) anti to the attacking dioxiranes and the smallest group(H) inside due to the effect of allylic 1,3-strain.⁷ Moreover, we assume that the observed higher selectivities in entries 15 and 17 of Table 1, can be attributed to the repulsion between R¹ and R²(=Me). In the case of olefin **1c**, *threo* selectivities were observed because interaction between R¹ and R⁴(=Me) might make transition state I unstable.^{3c}

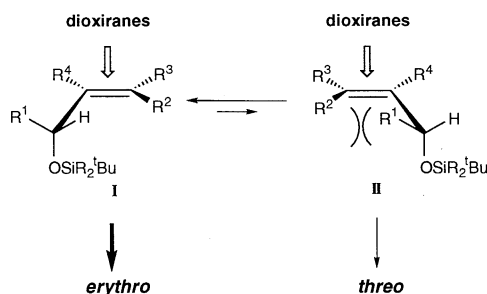


Figure 2.

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